10/613.697

451					10/613,691		
Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp	
S1	1037	700/245 ccls.	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/25 09:47	
S2	0	700/121ccls.	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/25 09:47	
S3	1227	700/121.ccls	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/25 09:47	
S4	129	700/114.ccls.	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/25 09:47	
S5	26	S3 AND S4	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/25 09:53	
S6	208	substrate WITH ((alignment OR aligning) WITH calibrat\$3)	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/25 10:13	
S7	1	S4 AND S6	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/25 09:55	
S8	2	S3 AND S6	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/25 09:55	
S9	140482	substrate WITH position\$3	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/27 15:19	
S10	15	S4 AND S9	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/25 10:37	
S11	1	"5102280":pn	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/25 10:45	
S12	117	S6 SAME S9	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/26 08:58	
S13	1429	414/744.\$.ccls.	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/25 12:25	
S14	0	S12 AND S13	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/25 10:45	
S15	208	substrate WITH ((alignment OR aligning) WITH calibrat\$3)	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/25 12:25	
S16	1429	414/744.\$.ccls.	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/25 12:25	
S17	0	S15 AND S16	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/25 12:25	

<u> </u>	1	T	I	T	r -	2225
S18	74	("3694741" "3706919" "3771051" "3775678" "3775679" "3805150" "3812424" "3815111" "3986109" "3990005" "4158171" "4217542" "4228392" "4353029" "4457664" "4619575" "4620831" "4646009" "4692695" "4746256" "4749330" "4750141" "4789294" "4836733" "4880348").PN. OR ("5102280"). URPN.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/04/25 12:28
S19	208	substrate WITH ((alignment OR aligning) WITH calibrat\$3)	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/25 14:12
S20	140482	substrate WITH position\$3	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/25 14:10
S21	89	S19 WITH S20	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/25 14:11
S22	48	S19 WITH S20	USPAT; EPO; JPO	OR	OFF	2005/04/25 14:11
S23	11312	substrate WITH ((alignment OR aligning) WITH (device\$ OR process\$2))	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/25 14:13
S24	2146	S23 WITH S20	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/25 14:13
S25	1037	700/245.ccls.	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/25 14:14
S26	1227	700/121.ccls.	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/25 14:14
S27	129	700/114.ccls.	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/25 14:14
S28	1429	414/744.\$.ccls.	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/25 14:14
S29	14	(S25 OR S26 OR S27 OR S28) AND S24	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/25 14:14
S30	25	("3694741" "3706919" "3771051" "3775678" "3775679" "3805150" "3812424" "3815111" "3986109" "3990005" "4158171" "4217542" "4228392" "4353029" "4457664" "4619575" "4620831" "4646009" "4692695" "4746256" "4749330" "4750141" "4789294" "4836733" "4880348").PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/04/26 08:55

S31	208	substrate WITH ((alignment OR aligning) WITH calibrat\$3)	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/26 08:58
S32	140610	substrate WITH position\$3	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/26 08:58
S33	89	S31 WITH S32	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/26 08:58
S34	48	S31 WITH S32	USPAT; EPO; JPO	OR	OFF	2005/04/26 09:01
S35	25	\$3align\$4 WITH calibrat\$4 WITH synchroniz\$3	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/26 09:04
S36	1041	700/245.ccls.	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/26 09:04
S37	129	700/114.ccls.	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/26 09:04
S38	2	S37 AND S36	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/26 09:10
S39	1161068	(robot OR apparatus OR device) WITH (position\$3 OR align\$4)	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/27 15:22
S40	21747	(substrate WITH position\$3) SAME (substrate WITH process\$3)	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/27 15:20
S41	2173	((substrate WITH position\$3) SAME (substrate WITH process\$3)) SAME (alignment OR aligning)	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/27 15:20
S42	324812	((substrate WITH position\$3) SAME (substrate WITH process\$3)) SAME (alignment OR aligning)"." ti, ab, "clm."	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/27 15:21
S43	754	((robot OR apparatus OR device) WITH (position\$3 OR align\$4)) SAME S41	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/27 15:22
S44	1230	700/121.ccls.	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/27 15:22
S45	5	S43 AND S44	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/27 15:33
S46	4015	(calibration OR calibrating OR calibrate) WITH (aligning OR alignment)	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/27 15:38
S47	870	((calibration OR calibrating OR calibrate) WITH (aligning OR alignment)) WITH (robot OR device OR apparatus)	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/27 15:39

S48	1	(transport WITH substrate) SAME S47	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/27 15:39
S49	299	((calibration OR calibrating OR calibrate) WITH (aligning OR alignment)) WITH (substrate OR mask OR IC OR semiconductor)	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/27 15:40
S50	156	((calibration OR calibrating OR calibrate) WITH (aligning OR alignment)) WITH (substrate OR mask OR IC OR semiconductor)	USPAT	OR	OFF	2005/04/27 15:40
S51	1	"6195619".pn.	US-PGPUB; USPAT; EPO; JPO	OR	OFF	2005/04/27 15:59